FORM PTO-1449	Docket Number (Optional) 2080-3-62	Application Number 10/034,457
INFORMATION DISCLOSURE CITATION IN AN APPLICATION	Applicant Myung-Won Lee	
(Use several sheets if necessary)	Filing Date 12/28/2001	Group Art Unit 2879 ~~2879~~

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U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
JW	WO 98/49706	11/05/1998	Samoff Corporation	H01J	9/00	

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION (YES/NO)
JW	JP11250798	09/17/1999	Japan	H01J	9/02, 9/20, 11/02,17/04	Yes (Abstract)
JW	JP11153860	06/08/1999	Japan	G03F H01J	7/004 9/02, 9/20, 11/02, 17/16	Yes (Abstract)
JW	EP0924739	06/23/1999	EP	H01J C03C	9/20, 17/49 27/04	Yes

OTHER DOCUMENTS *(Including Author, Title, Date, Pertinent Pages, Etc.)*

JW	W-S Jang, et. al., "A New Low-Cost Process for Fabricating a Plasma Display Back Panel," SID '99 Digest, 1036-1038 (May, 1999)

EXAMINER	DATE CONSIDERED
Joseph Williams	1/3/05

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.